

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)
Adrien Dromard et al.) Group Art Unit: 1793
Application No.: 10/583,417) Examiner: Serena L. Hanor
Filing Date: April 26, 2007) Confirmation No.: 3689
Title: HIGHLY-STRUCTURED SILICA)
HAVING A LOW WATER UPTAKE,)
PREPARATION METHOD THEREOF)
AND USES OF THE SAME)

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The following extension of time is requested to: respond to Official Action dated February 17, 2009 for

Three Months to May 17, 2009

☒ \$ 1110

☐ \$ 555

☒ Charge \$ 1110 to credit card. Form PTO-2038 is attached.

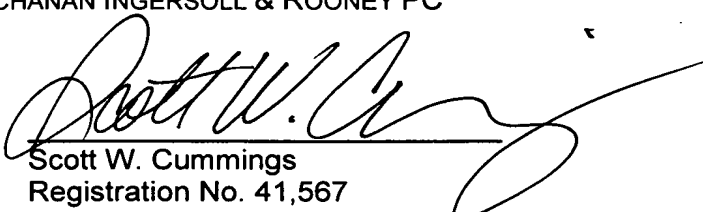
The Director is hereby authorized to charge any appropriate fees under 37 C.F.R. §§1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

BUCHANAN INGERSOLL & ROONEY PC

Date: August 17, 2009

By:


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